



PATENT APPLICATION
Do. No. 5484-48

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: **Byung-Sup SHIM et al.**

Serial No. 09/305,240

Examiner: O. Nadav

Filed: May 4, 1999

Group Art Unit: 2811

For: **OPEN DRAIN INPUT/OUTPUT STRUCTURE AND MANUFACTURING
METHOD THEREOF IN SEMICONDUCTOR DEVICE**

Date: July 17, 2000

Box Non-Fee Amendment
Commissioner of Patents and Trademarks,
Washington, D.C. 20231

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AMENDMENT & RESPONSE TO OFFICE ACTION

Responsive to the Office Action, dated April 17, 2000, please amend the application as follows.

IN THE SPECIFICATION

In page 1, at the beginning of the specification, immediately after the title, please add:

CROSS REFERENCE TO RELATED APPLICATIONS

This application claims priority from Korean Priority Document No. 1998-15975, filed on May 4, 1998 with the Korean Industrial Property Office, which document is hereby incorporated by reference.

In page 2, line 8, please insert - -with- - between "in series" and "each other".